

**COLLABORATION ON
RDM IN LOW-
TEMPERATURE PLASMA
PHYSICS**

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LAB SITUATION IN SCIENCE I



Hello, I am the next PhD student in the project. Could you please forward your previous data to me?



Hello, nice to meet you. Sure, please log in to our central repository. There you will find all measurement data according to our metadata standards from my scientific work.

LAB SITUATION IN SCIENCE II



Hello, I am the next PhD student in the project. Could you please forward your previous data to me?




Hello, nice to meet you. I'm very sorry. The lab was flooded by cooling water, so my lab book was destroyed. But yes, the data I collected is on these 10 different CDs. So, help yourself.


RECIPE FOR FAIR DATA



RECIPE FOR FAIR DATA

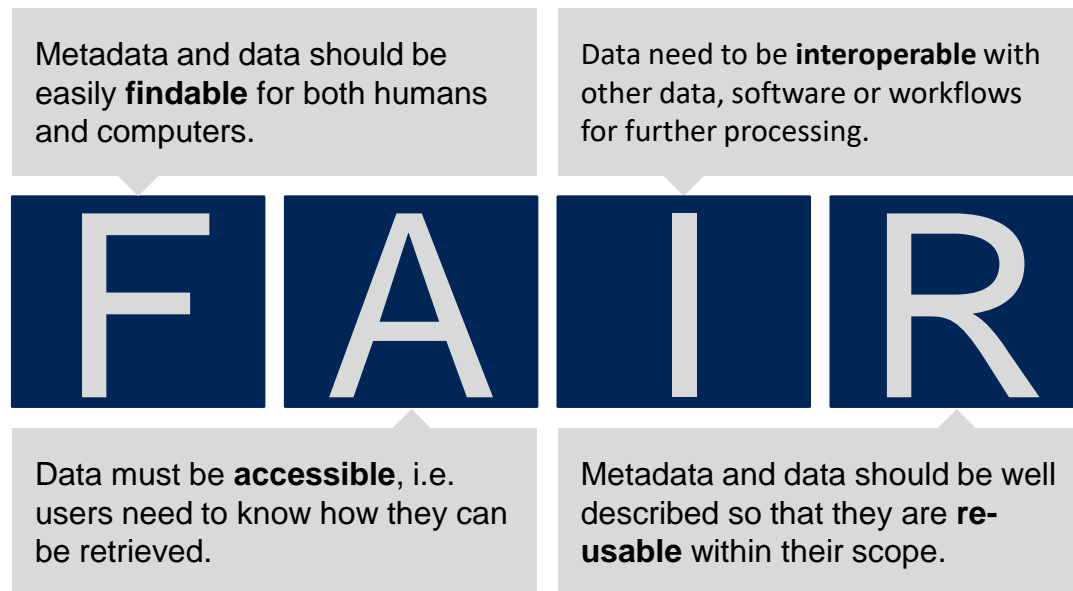


Is there any recipe to achieve FAIR data?



Unfortunately, there is no single recipe for this. But I'm happy to show you what it's all about and what activities are available so far.

FAIR DATA

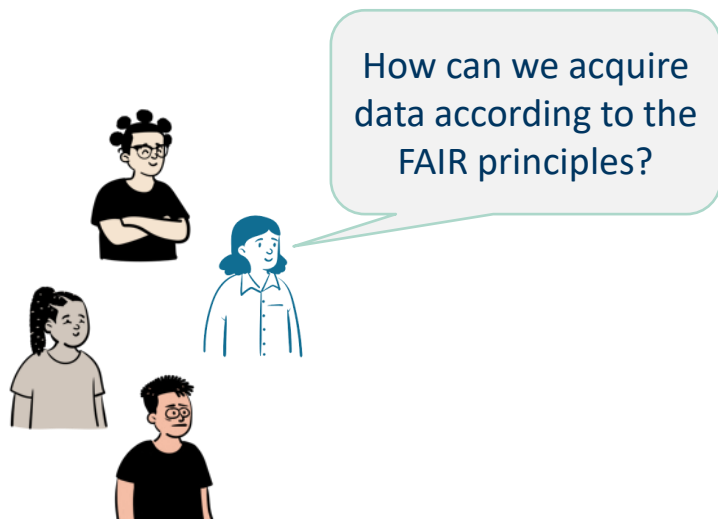


DATA LIFE CYCLE

- Six steps define the data life cycle
- Process Scientific data should be handled according to the FAIR principle
- Various aspects of processing are required to find solutions
- Common challenges in the research groups



DATA ACQUISITION



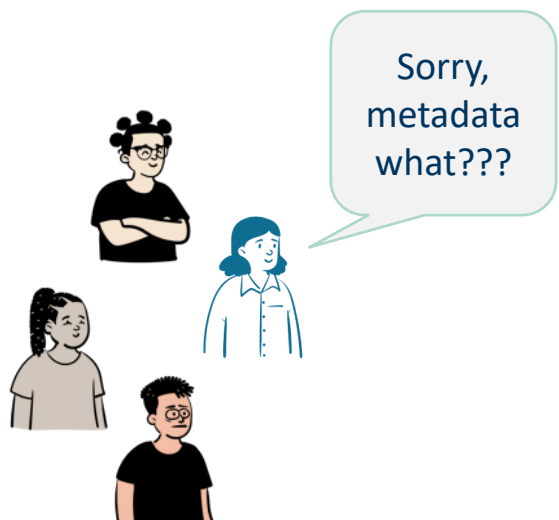
DATA ACQUISITION

How can we acquire data according to the FAIR principles?

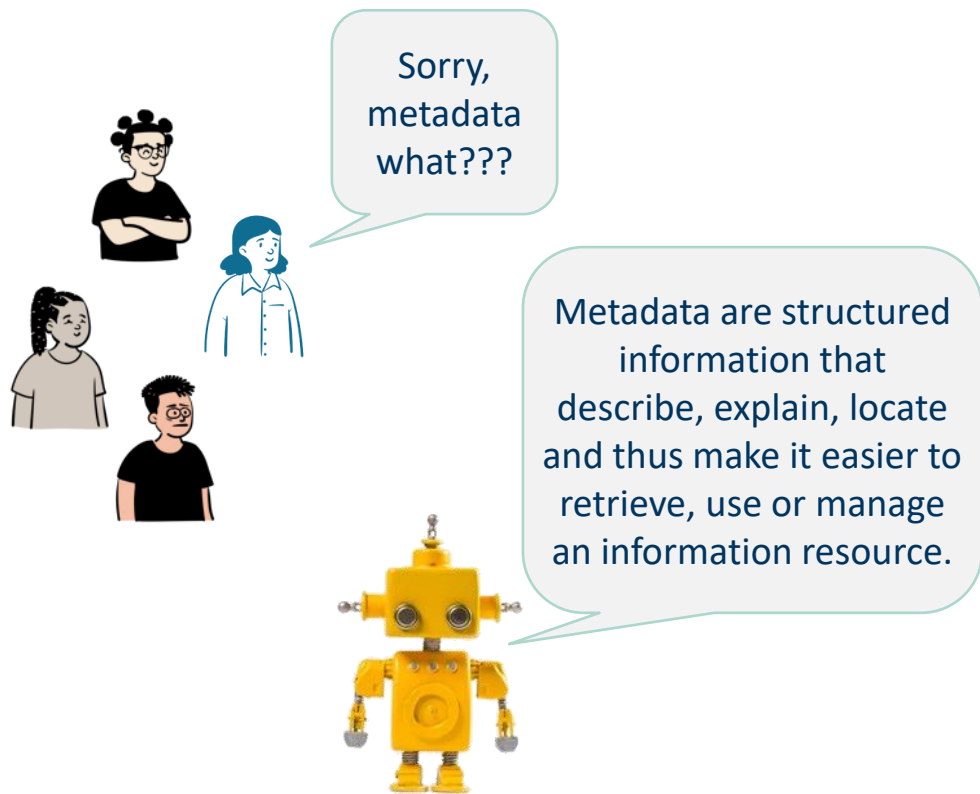
Using an electronic lab book with uniform metadata schemas is the common way.



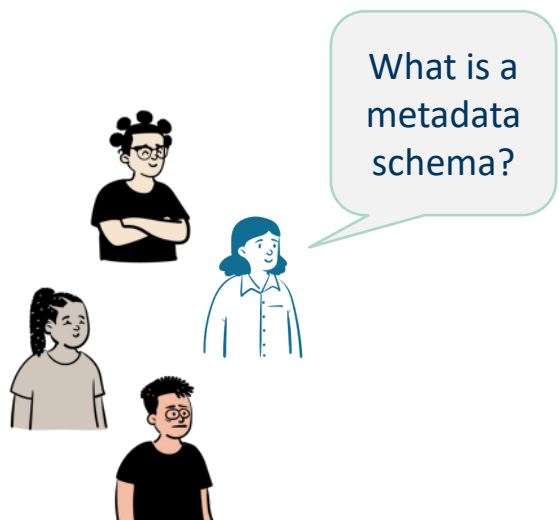
DATA ACQUISITION




DATA ACQUISITION



DATA ACQUISITION



DATA ACQUISITION



What is a metadata schema?

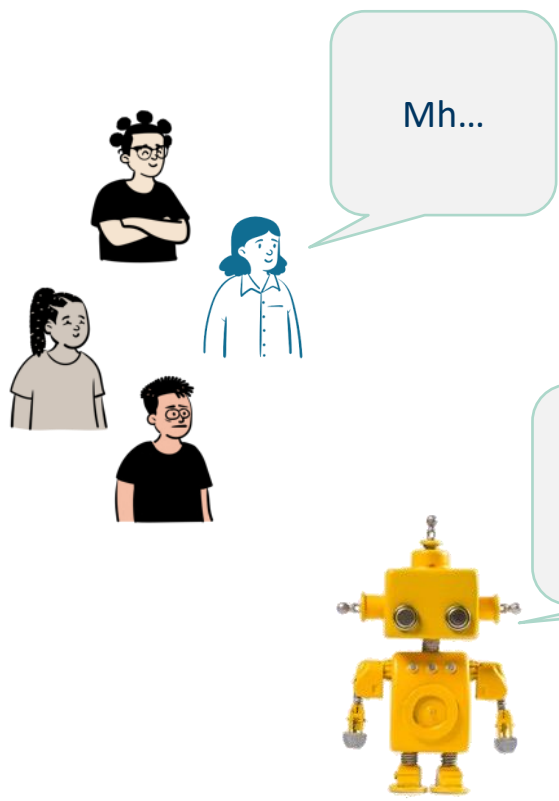
Metadata schemas supports the collection of structured metadata.



DATA ACQUISITION



DATA ACQUISITION



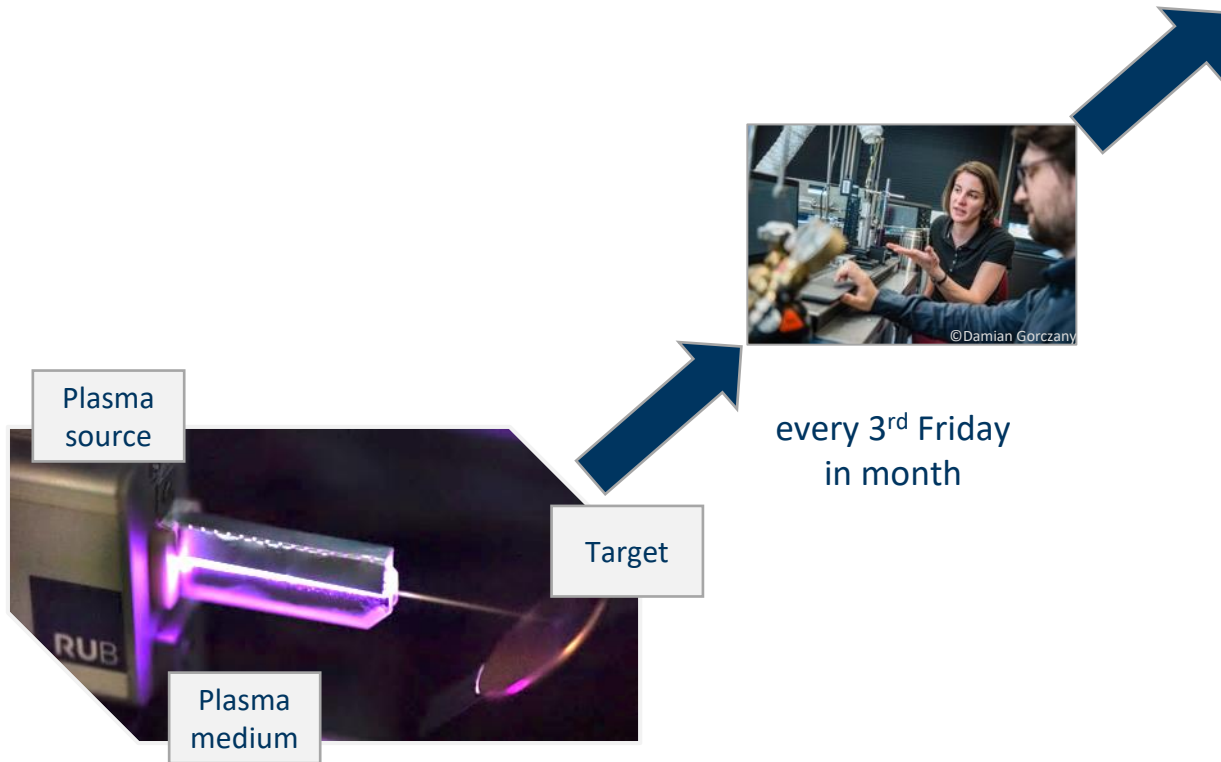
METADATA STANDARDS

Example dinosaur game

- The dinosaurs are compared with each other
- Comparison needs to be defined by a defined description of the length, weight....



METADATA SCHEMA DEVELOPMENT INP, CAU, RUB



Plasma source

description of name and/or type of the plasma source including application the plasma source is applied for



Plasma medium

medium name the plasma source is operated in or acting on and properties of the medium the plasma source is operated in or acting on



Target

name of the target the plasma source is acting on, either directly or mediated by a medium and properties of the target the plasma source is acting on

METADATA SCHEMAS IN PLASMA SCIENCE

Example for metadata of APPJ device:

Id	Title	Unit	Description
1	Name		Name of the plasma source device
2	Serial number		Serial number of the plasma source device
3	Commercial product		Is the plasma source commercially available?
4	TRL		Technology Readiness Level (TRL)
5	Developer		Name of the institution / group where the plasma source has been developed
6	Documentation		Publication or other report describing the plasma source
7	Geometry		Description of the electrode configuration
8	Min. power	W	Minimum power dissipated in the plasma

METADATA SCHEMAS IN PLASMA SCIENCE

Example for metadata of APPJ device:

Id	Title	Unit	Description
9	Max. power	W	Maximum power dissipated in the plasma
10	Reflected power	%	Part of the input power which is reflected and not coupled to the electrode
11	Min. voltage (p-p)	V	Minimum peak-to-peak voltage
12	Max. voltage (p-p)	V	Maximum peak-to-peak voltage
13	Min. frequency	Hz	Minimum frequency of the voltage signal
14	Max. frequency	Hz	Maximum frequency of the voltage signal
15	Min. current (p-p)	A	Minimum peak-to-peak current
16	Max. current (p-p)	A	Maximum peak-to-peak current

METADATA STANDARDS IN PLASMA SCIENCE

Github for metadata documentation

- <https://github.com/plasma-mds/plasma-metadata-schema>



Meetings are announced here

- <https://www.plasma-mds.org/ws-metadata.html>

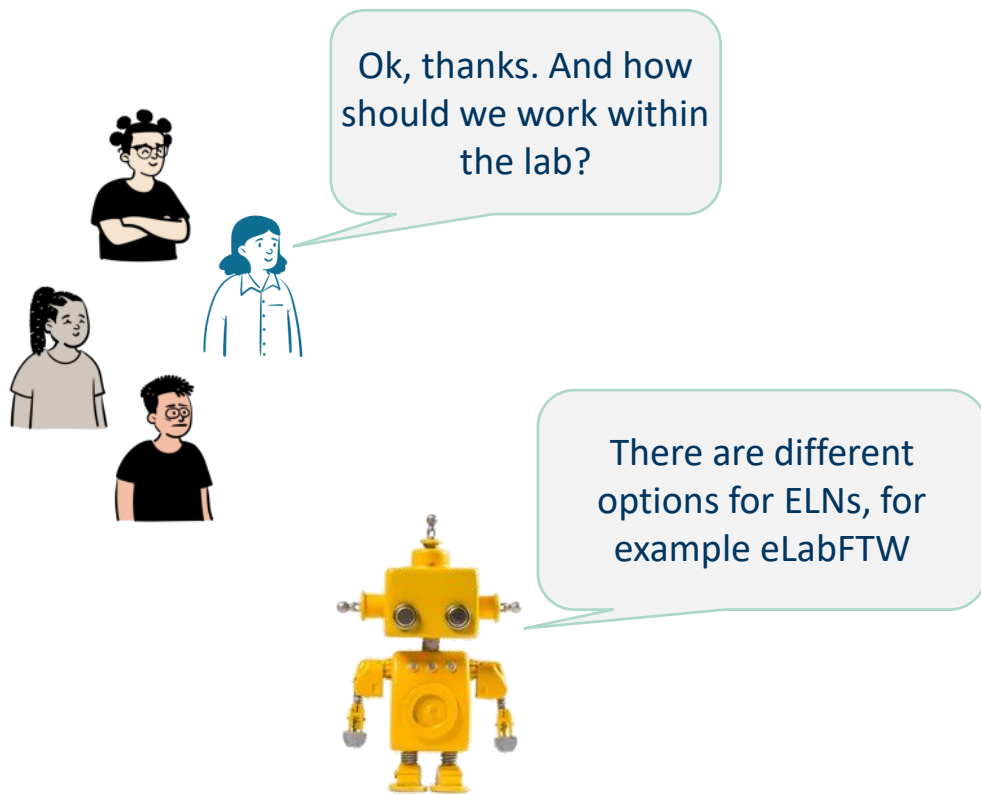


We look forward to an exchange and participation from you!

ELECTRONIC LAB NOTEBOOK (ELN)



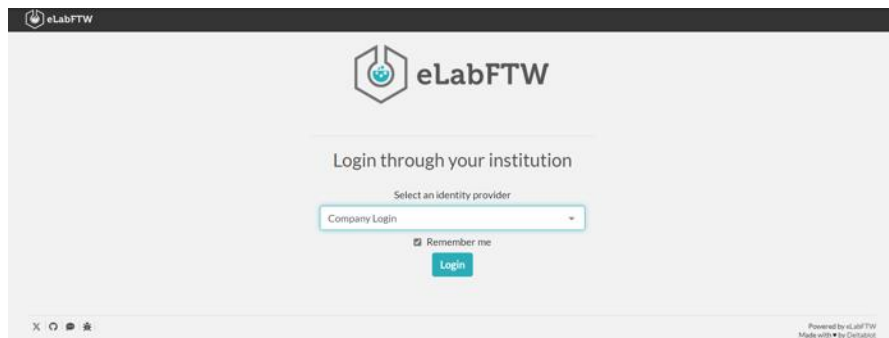
ELECTRONIC LAB NOTEBOOK (ELN)



ELECTRONIC LAB NOTEBOOK (ELN)

eLabFTW

- Open-source ELN system with increasing popularity at research institutions in Europe
 - In productive use at INP, CAU and RUB
- Statistics: >150 members >1,000 Experiments
- Next step: Replacement for hand-written lab books or other digital solutions, such as Excel, Word, MS Notes



RESEARCH DATA LIFECYCLE

Measures within RDM adapted to research data lifecycle

- From planning of data collection to re-use of the data
- Storage and processing needs to be supported



XPS METADATA SCHEMA

Measurement data schema available

- Community activity
- Iterations between meetings
- Now in testing phase
- Publication in GitHub

Id	Key	Title	Unit	Description	Type	Occ	Allowed values
1	name	Name		Name of the XPS device	string	1	
2	sn	Serial number		Serial number of the device	string	0-1	
3	developedBy	Developer		Name of the company	string	1	
4	AngleSourceValue	Angle between source and analyser	°	Angle between source and analyser	number	1	
5	Aperture	Aperture of the device		Aperture of the device	string	1	
6	ReferenceScalePE	Reference scale PE	eV	By giving position and FWHM of a ref material at a reference PE	number	1	
6.1	ReferenceScaleAu	Reference scale Au	eV	By giving position and FWHM of a ref material at a reference Au	number	1	
6.2	ReferenceScaleAg	Reference scale Ag	eV	By giving position and FWHM of a ref material at a reference Ag	number	1	
6.3	ReferenceScaleCu	Reference scale Cu	eV	By giving position and FWHM of a ref material at a reference Cu	number	1	
6.4	ReferenceScaleC	Reference scale C	Ev	By giving position and FWHM of a ref material at a reference C	number	1	
7	Detector	Detector type		Type and name of the detector	string	1	
8	MaintenanceDate	Last maintenance date		The date date of maintenance	string	1	

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Device
description

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Device description

Id	Key	Title	Unit	Description	Type	Occ	Allowed values
1	Experiment	Experiment description		Description of the experiment		1	
1.1	BeamDiameterValue	XPS beam diameter	µm	Beam diameter of the XPS measurement	number	1	
1.2	Tilt	Tilt angle	°	Tilt angle of measurement	number	1	
1.3	PressureValue	XPS pressure		Pressure during measurements	string	1	
1.4	Holder	Sample holder		Which sample holder is used	string	1	
1.5	AngleRes	Angle resolution		Angle resolution of measurement	string	0	
2	SampleID	Sample ID		Sample ID	string	1	
2.1	FileName	File name		File name	string	1	
2.2	ReceivedCondition	As received condition		As received condition	string	1	
2.3	TemperatureSample	Sample temperature	K	Temperature of the sample during measurement	number	1	
2.4	Neutralize	Neutralization conditions		Neutralization on/off	boolean	1	
2.5	RepeatNumber	Repeats of measurement		Number of repeats of the whole measurement setting	number	0	
3	Peak	Peak description		Description of the peaks		1-n	

Measurement info

XPS METADATA SCHEMA

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Device
description

Id	Key	Title	Unit	Description	Type	Occ	Allowed values
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1.1	BeamDiameterValue	XPS beam diameter	µm	Beam diameter of the XPS measurement	number	1	
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1.4	Holder	Sample holder		Which sample holder is used	string	1	
1.5	AngleRes	Angle resolution		Angle resolution of measurement	string	0	
2	SampleID	Sample ID		Sample ID	string	1	
2.1	FileName	File name		File name	string	1	
2.2	ReceivedCondition	As received		As received to	string	1	
2.3	TemperatureSample	Sample temperature	K	Temperature of the sample during measurement	number	1	
2.4	Neutralize	Neutralization conditions		Neutralization on/off	boolean	1	
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Measurement
info

XPS METADATA SCHEMA

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- Community activity
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- Now in testing phase
- Publication in GitHub

Id	Key	Title	Unit	Description	Type	Occ	Allowed values
1	General	General information		General information for processing the fit	string	1	
1.1	Normalization	Normalization		Normalization (reference for fit)	string	1	
1.2	IntensityFactor	Intensity factor		Intensity factor (name/storage)	string	1	
1.3	ReferencePaper	Reference paper		Information about the reference	string	0	
2	Component	Analysed component				1-n	
2.1	Background	Background				1	
2.2	Fit type	Fit type				1	singlet; doublet
2.3	Profile	FitProfile		Fit profile	boolean	1	Voigt; Lorentzian
2.4	ChemicalAssign	Chemical assignment		Chemical assignment of component	string	0	
2.5	Position	Position component	eV	Absolut or relative position for component	number	1	
2.6	FWHM		eV	FWHM	number	1	
2.7	Profile ratio	Profile ratio		Lorentz/Gauß ratio	string	0	
2.8	Asymmetry	Asymmetry or comments		Asymmetry in peak? or other comments	string	0	

Analysis documentation

Id	Key	Title	Unit	Description	Type	Occ	Allowed values
1	Experiment	Experiment description		Description of the experiment			
1.1	BeamDiameterValue	XPS beam diameter	µm	Beam diameter of the XPS measurement			
1.2	Tilt	Tilt angle	°	Tilt angle of measurement			
1.3	PressureValue	XPS pressure		Pressure during measurements	string	1	
1.4	Holder	Sample holder		Which sample holder is used	string	1	
1.5	AngleRes	Angle resolution		Normal	string	0	
2	SampleID	Sample ID			string	1	
2.1	FileName	File name			string	1	
2.2	ReceivedCondition	As received condition		Received to	string	1	
2.3	TemperatureSample	Sample temperature	K	Temperature of the sample during measurement	number	1	
2.4	Neutralize	Neutralization conditions		Neutralization on/off	boolean	1	
2.5	RepeatNumber	Repeats of measurement		Number of repeats of the whole measurement setting	number	0	
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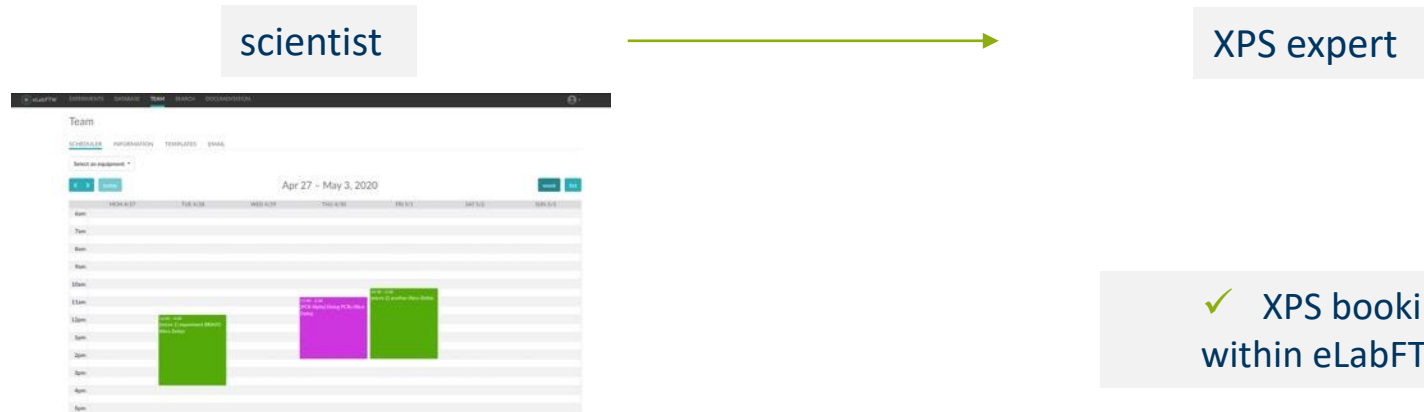
Measurement info

Id	Key	Title	Unit	Description	Type	Occ	Allowed values
1	name	Name		Name of the XPS device	string	1	
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7	Detector	Detector type		Type and name of the detector	string	1	
8	MaintenanceDate	Last maintenance date		The date date of maintenance	string	1	

Device description

STEP 1 – APPOINTMENT BOOKING

User acquires XPS appointment in eLabFTW calendar



STEP 2 – XPS SAMPLE TRANSITION

User hands over samples for measurement



STEP 3 – XPS MEASUREMENT

XPS measurement is done

scientist

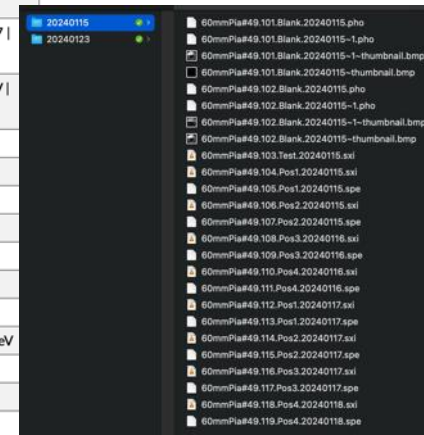
XPS expert

- ✓ XPS acquisition with minimum documentation effort

Measurement details

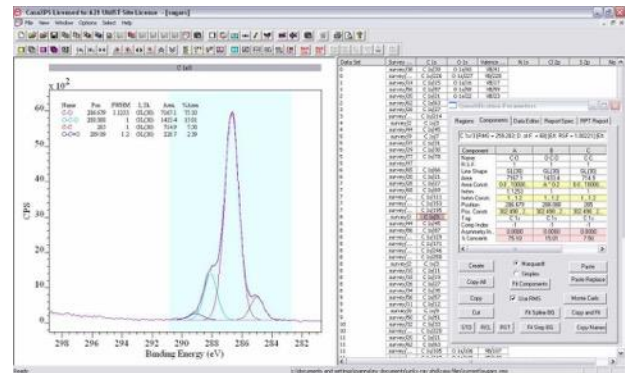
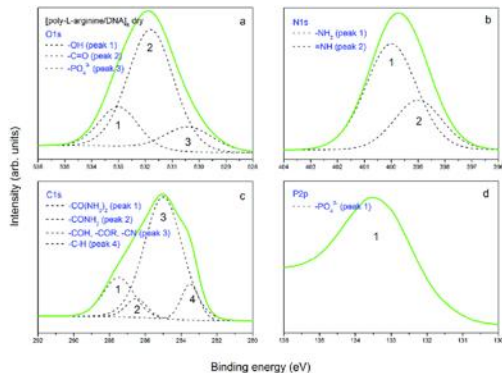
File name	Pia#49
Position	Pos. 1
Peak name	Surv O1s C1s Si2p
Binding energy	-5/1200 523/18 273/27 90/18
Pass energy	187.85eV 23.5eV 23.5eV 23.5eV
Scan number	1 1 2 3 5
Cycles	3

File name	Pia#49
Position	Pos. 2
Peak name	Surv O1s C1s
Binding energy	-5/1200 523/18
Pass energy	187.85 eV 23.5 eV 23.5 eV
Scan number	1 1 2 3
Cycles	3



STEP 4 – XPS ANALYSIS

XPS analysis is done




✓ Publication including all relevant information by extracting eLabFTW information

RE-USE



RE-USE




And how can others
re-use my scientific
data?

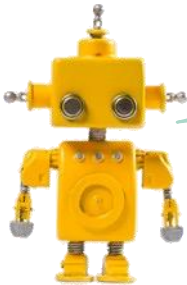
We would like to
distinguish between
internal and external
usage.



RE-USE - STORAGE



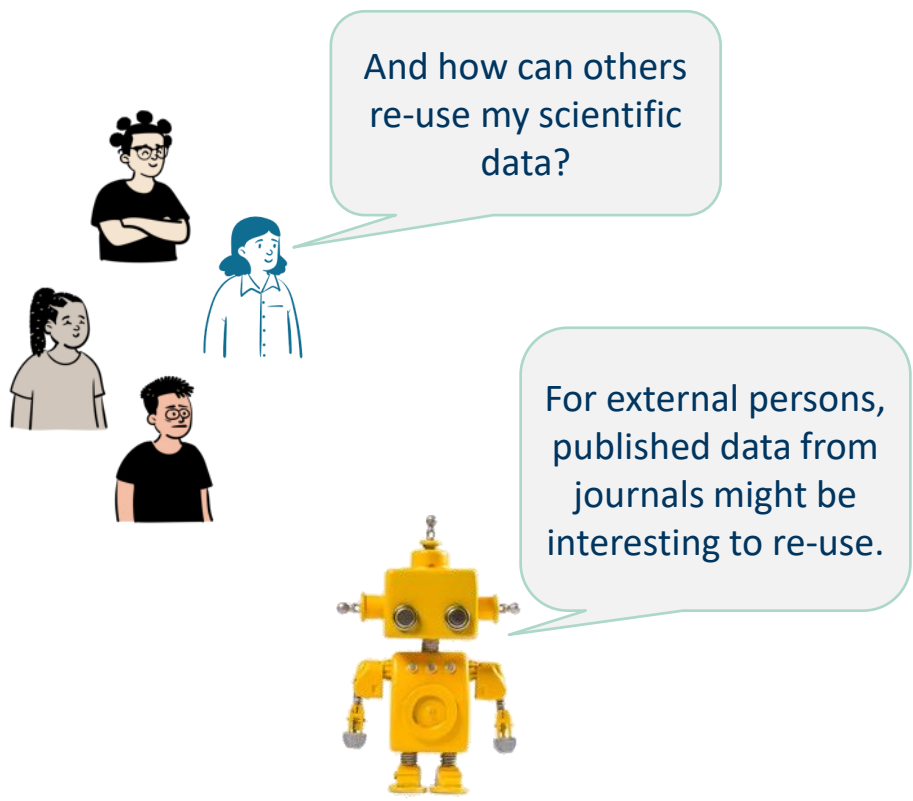
And how can others
re-use my scientific
data?



Storage is more secure on a
medium that can be accessed
by other people and is
organized according to
appropriate standards.



RE-USE - REPOSITORY



METADATA SCHEMAS & REPOSITORY

Filter by structured data is possible

Id	Key	Title	Unit	Description	Type	Occ	Allowed values
1	General	General information		General information for processing the fit	string	1	
1.1	Normalization	Normalization		Normalization (reference for fit)	string	1	
1.2	IntensityFactor	Intensity factor		Intensity factor (name/storage)	string	1	
1.3	ReferencePaper	Reference paper		Information about the reference paper	string	0	
2	Component	Analysed component		Analysed component	string	1-n	
2.1	Background	Background		Background fit	string	1	
2.2	Fit type	Fit type		Fit type	boolean	1	singlet; doublet
2.3	Profile	FitProfile		Fit profile	boolean	1	Voigt; Lorentzian
2.4	ChemicalAssign	Chemical aissignment		Chemical assignement of component	string	0	
2.5	Position	Position component	eV	Absolut or relative position for component	number	1	
2.6	FWHM	FWHM	eV	FWHM	number	1	
2.7	Profile ratio	Profile ratio		Lorentz/Gauß ratio	string	0	
2.8	Asymmetry	Asymmetry or comments		Asymmetry in peak? or other comments	string	0	

METADATA SCHEMAS & REPOSITORY

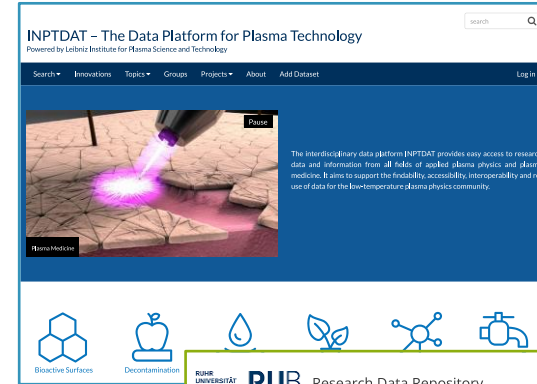
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REPOSITORY

- Data platform for the publication and linking of datasets, patents and plasma sources
 - Potential to use also as “expert database”
 - In productive use at INP inptdat
 - In productive use at RUB rdpcidat
 - Next step: broader use for the publication of plasma sources, technology offers and datasets belonging to scientific publications
- 🔗 citable DOI for the data



REPOSITORY - EXAMPLE



EP2



The group "Experimental Physics II - Reactive Plasmas" at the faculty of physics and astronomy at Ruhr University Bochum.

License

License Not Specified

Other Access

The information on this page (the dataset metadata) is also available in these formats.

 JSON  RDF

via the [DKAN API](#)

Simulated electric field magnitude of microwave plasma torch

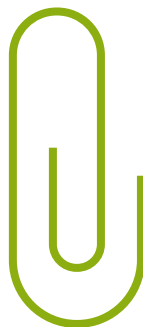
 Plasma Modeling and Simulation  Plasma Chemical Processes

Magnitude of the electric field of the microwave plasma torch simulated with ansys HFSS

[microwave](#) [electric field](#)

Dataset Info

Field	Value
Publisher	EP2
Authors	S. Kreuznacht
Release Date	2023-09-25
Identifier	f7313ed3-7fe9-4422-ae8-04af02532006
Permanent Identifier (URI)	https://rdpcidat.rub.de/node/737
Plasma Source Name	Microwave plasma torch
Plasma Source Application	Methane pyrolysis
Plasma Source Specification	sinusoidal waveform 2.45 GHz atmospheric pressure
License	License Not Specified
Plasma Medium Name	Ar

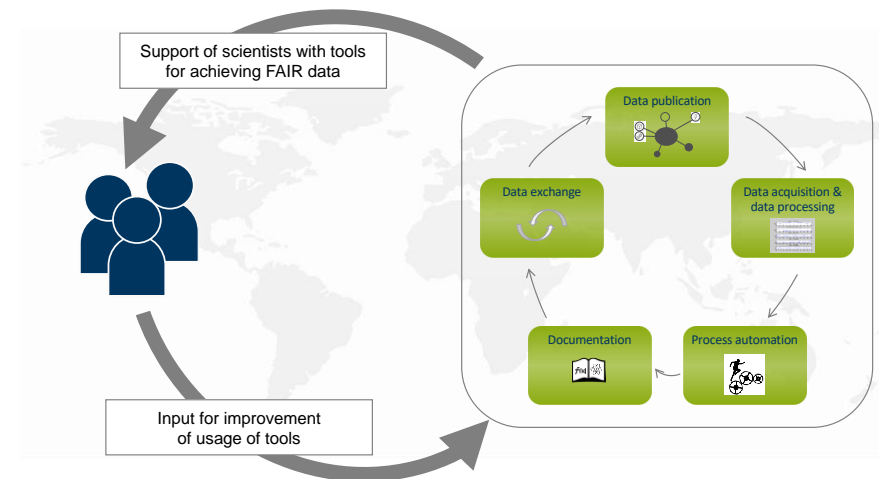


Download of raw data

SUMMARY

Aim of collaboration between plasma science groups of CAU, INP & RUB

- Development of methods and tools for research data management in low-temperature plasma physics
- Repository usage for data sets of peer-reviewed articles, Plasma-MDS for homogeneous metadata
- Highly addressing the community aspects
- Joint working groups for definition of metadata standards and quality criteria



SUBSCRIBE FOR eMAIL LIST

**Mailing list for metadata discussion &
announcement of workshops or other activities**



SUBSCRIBE FOR eMAIL LIST

**Mailing list for metadata discussion &
announcement of workshops or other activities**



Thank you for your kind
attention!